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(54) COMPOUND SEMICONDUCTOR CRYSTAL GROWTH AND COMPOUND SEMICONDUCTOR DEVICE

PURPOSE: To produce a compound semiconductor layer having hetero interfaces so as to acquire such steep hetero interfaces as to have a precision of monatomic layer, by feeding, using the atomic layer epitaxy technique, a semiconductor substrate with the feedstocks of elements constituting the title compound semiconductor in high flow rate at low-growth temperature and low-growth pressure.

CONSTITUTION: Using the atomic layer epitaxy technique, a semiconductor substrate is alternately fed with the feedstocks of elements constituting the objective compound semiconductor to effect monatomic layer growth of the superlattice structure layer of (GaAs)m(GaP)n, (GaAs)m(GaAsP)n, (GaAsP)m(GaP)n or (GaAs)l (GaAsP)m(GaP)n (I, m and n are each positive integer). It is preferable that the feedstocks for Ga, As and P be trimethylgarium, arsine and phosphine, respectively, and said semiconductor substrate be fed with the trimethylgarium in high flow speed at low-growth temperature and pressure to effect monatomic layer growth through decomposition reaction on said substrate's surface.

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